

Due: Friday, February 07, 2003

1. In practice we assume that the intrinsic Fermi level,  $E_i$ , coincides with the center of the band gap. In reality it is not true. Derive an expression relating the intrinsic level  $E_i$  to the center of the band gap. Find the displacement of  $E_i$  from the center of the band gap for both silicon and germanium at room temperature. The effective mass values are  $m_n^* = 0.55 m_0$  for Ge and  $1.1 m_0$  for Si,  $m_p^* = 0.37 m_0$  for Ge and  $0.56 m_0$  for Si where  $m_0$  is the free electron mass.

Solutions:

Equation (3-15):  $n_0 = N_c e^{-(E_c - E_F)/kT}$ , for intrinsic material,  $n_0 = n_i$ ,  $E_F = E_i$ ,  $n_i = N_c e^{-(E_c - E_i)/kT}$

Equation (3-23):  $n_i = \sqrt{N_c N_v} e^{-E_g/2kT}$

Therefore,  $\sqrt{N_c N_v} e^{-E_g/2kT} = N_c e^{-(E_c - E_i)/kT}$ , after simplification, we have:

$$E_i = E_c - \frac{E_g}{2} + kT \ln \sqrt{\frac{N_v}{N_c}}$$

The energy level at the center of band gap  $E_{center} = E_c - \frac{E_g}{2}$

The displacement  $E_i - E_{center} = kT \ln \sqrt{\frac{N_v}{N_c}}$

Equation (3-16), (3-20),  $N_c = 2 \left( \frac{2p m_n^* kT}{h^2} \right)^{3/2}$ ,  $N_v = 2 \left( \frac{2p m_p^* kT}{h^2} \right)^{3/2}$

So we have  $E_i - E_{center} = \frac{3}{4} kT \ln \frac{m_p^*}{m_n^*}$  (\*\*)

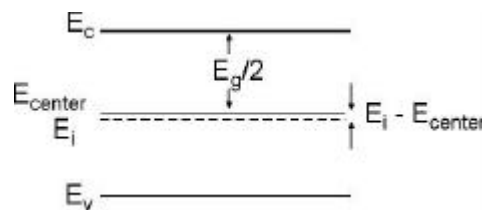
At  $T = 300K$ ,  $kT = 1.38 \times 10^{-23} \times 300 = 4.14 \times 10^{-21} J = 0.0259 eV$

For silicon,  $m_n^* = 1.1 m_0$ ,  $m_p^* = 0.56 m_0$

$$E_i - E_{center} = \frac{3}{4} kT \ln \frac{m_p^*}{m_n^*} = -0.013 eV$$

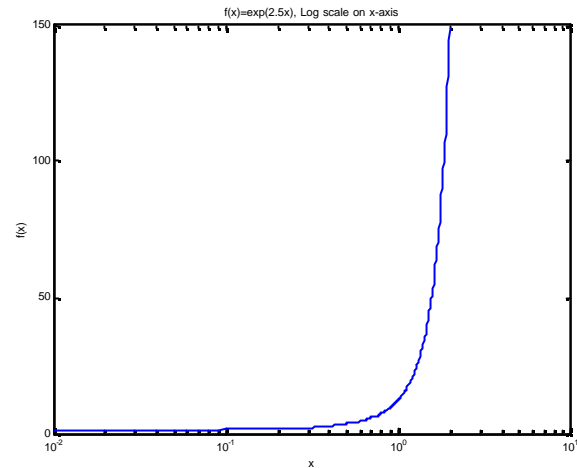
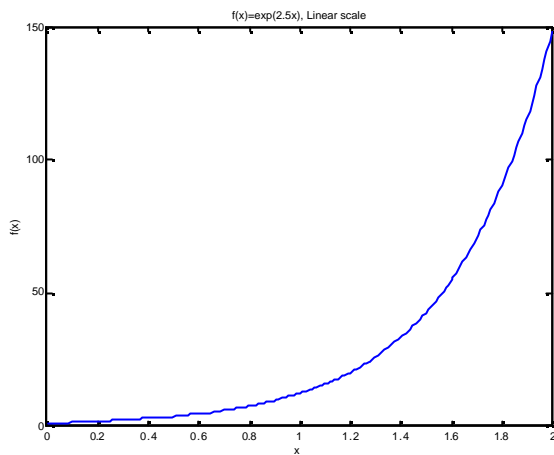
For Ge,  $m_n^* = 0.55 m_0$ ,  $m_p^* = 0.37 m_0$

$$E_i - E_{center} = \frac{3}{4} kT \ln \frac{m_p^*}{m_n^*} = -0.0077 eV$$



2. Math exercise: plot the function  $f(x) = \exp(2.5x)$  from  $x=0.01$  to  $2.0$  in two graphs. One is on a linear scale and the other on semi-logarithmic scale.

Solution:



The graphs plotted here has log scale in x-axis. It's also correct if having log scale on y-axis (which is a straight line). But with log scale on both axis is not correct.

3. A silicon sample is doped with  $1.5 \times 10^{14}$  Ga atoms/cm<sup>3</sup>. (a) What are the electron and hole concentrations, respectively, at 450 K under equilibrium conditions? (b) Where is  $E_F$  positioned relative to  $E_i$ ? (c) Draw the energy band diagram for the material assuming that  $E_i$  coincides with the center of the band gap.

Refer to Fig. 3-17 to obtain the intrinsic carrier concentration at 450 K. Also, the band gap energy is reduced to 1.08 eV at 450 K.

Solutions:

(a), Doped with Ga  $\rightarrow$  p-type.

Look up the Fig 3-17, at 450K,  $n_i \approx 8 \times 10^{13} \text{ cm}^{-3}$ . Since  $n_i \sim N_a$ , can't assume  $p = N_a$ , or  $p = N_a + n_i$

Charge neutrality equation:  $N_d^+ + p = N_a^- + n$ ,  $N_a = 1.5 \times 10^{14} \text{ cm}^{-3}$ ,  $N_d = 0$

At thermal equilibrium,  $n = n_i^2 / p$ ,

We have:  $p = N_a - N_d + \frac{n_i^2}{p}$ , or  $p^2 - (N_a - N_d)p - n_i^2 = 0$ , solving this quadratic equation gives:

$$p = \frac{1}{2} \left( N_a \pm \sqrt{N_a^2 + 4n_i^2} \right) = 1.85 \times 10^{14} \text{ cm}^{-3},$$

$$n = \frac{n_i^2}{p} = 3.47 \times 10^{13} \text{ cm}^{-3}$$

$$(b), E_F - E_i = kT \ln \frac{n_0}{n_i} = 0.0259 \ln \frac{3.47 \times 10^{13}}{8 \times 10^{13}} = -0.022 \text{ eV}$$

$E_F$  lies 0.022eV below  $E_i$ ,